

Nanopatterning: Market Research Report



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This report analyzes the Global market for Nanopatterning in US\$ Thousand by the following Technology Types - Nanoimprint Lithography (Hot Embossing Lithography, UV Nanoimprint Lithography, Soft Lithography, & Others), Scanning Probe Lithography, and Others. The Global market is further analyzed by the following End-Use Applications: Semiconductor & Other Microelectronics, and Others. Annual estimates and forecasts are provided for the period 2015 through 2022. Also, a six-year historic analysis is provided for this market. Market data and analytics are derived from primary and secondary research. Company profiles are primarily based on public domain information including company URLs. The report profiles 35 companies including many key and niche players such as -

- AMO GmbH
- Canadian Photonics Fabrication Centre
- EV Group
- IMS Chips
- Micro Resist Technology GmbH

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 EVG Unveils EVG720 Automated UV-NIL System

EVG Launches EVG PHABLE Exposure System

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Obducat Signs Agreement with a Display Manufacturer Regarding Evaluation of NIL Technology for Large Area

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Canon to Develop Next Generation Lithography System

Toshiba Partners with SK hynix for NIL Systems

SUSS MicroTec Inks with Singh Center for Nanotechnology for NIL

Canon Takes Over Molecular Imprints

EVG Establishes NILPhotonics Competence Center

EV Group Launches New SmartNIL

8. FOCUS ON SELECT PLAYERS

AMO GmbH (Germany)

Canadian Photonics Fabrication Centre (Canada)

EV Group (Austria)

IMS Chips (Germany)

Micro Resist Technology GmbH (Germany)

Molecular Imprints, Inc. (US)

Nanonex Corp. (US)

NanoOpto Corp. (US)

Nano-Terra, Inc. (US)

NIL Technology ApS (Denmark)

NTT Advanced Technology Corporation (Japan)

Obducat AB (Sweden)

PROFACTOR GmbH (Austria)

SET Corporation SA (France)

Sigma-Aldrich Corp. (US)

SUSS MicroTec AG (Germany)

SVG Optronics Co., Ltd. (China)

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III. COMPETITIVE LANDSCAPE

Total Companies Profiled: 35 (including Divisions/Subsidiaries - 37)

The United States (10)

Canada (1)

Japan (6)

Europe (17)

 France (2)

 Germany (7)

 Spain (1)

 Rest of Europe (7)

Asia-Pacific (Excluding Japan) (2)

Middle East (1)

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